

**A novel method  
to predict densities of amorphous materials  
from first-principles calculations**

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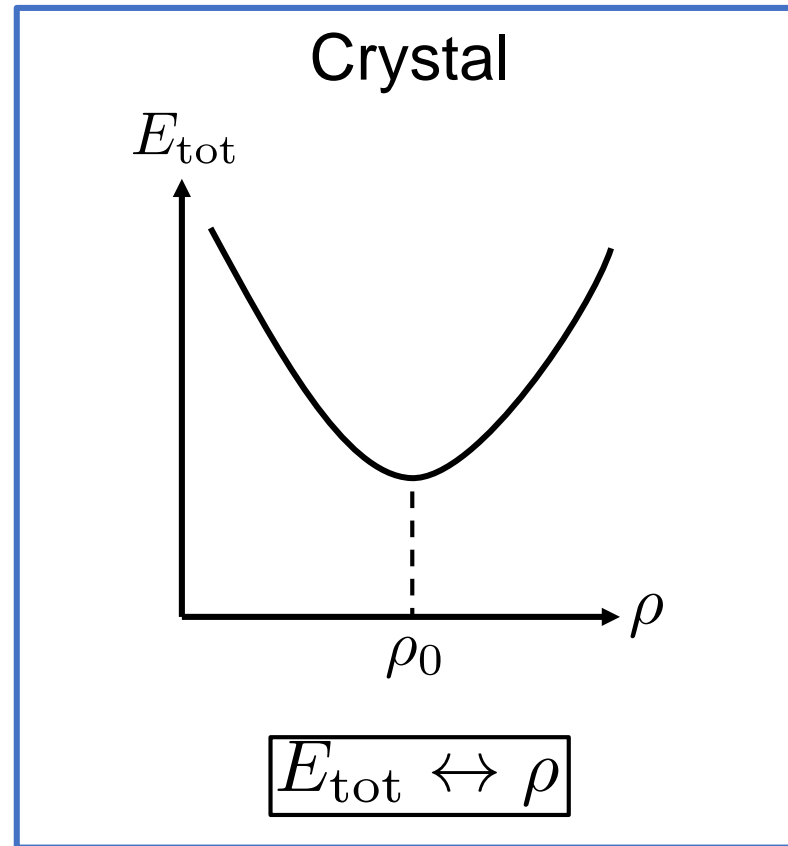
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(arxiv:1704.06107)

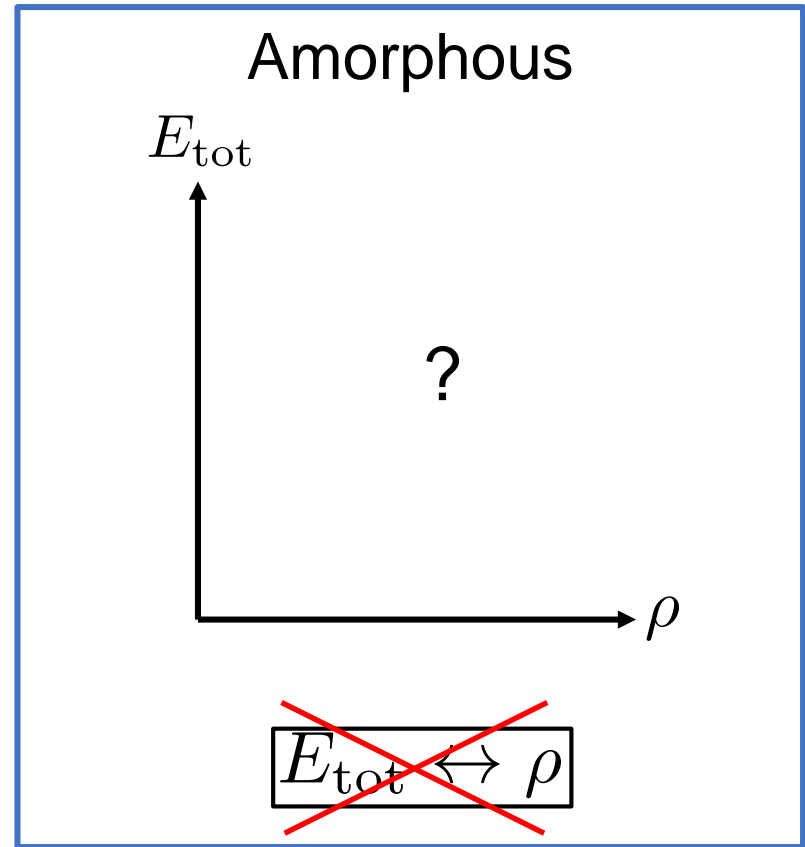
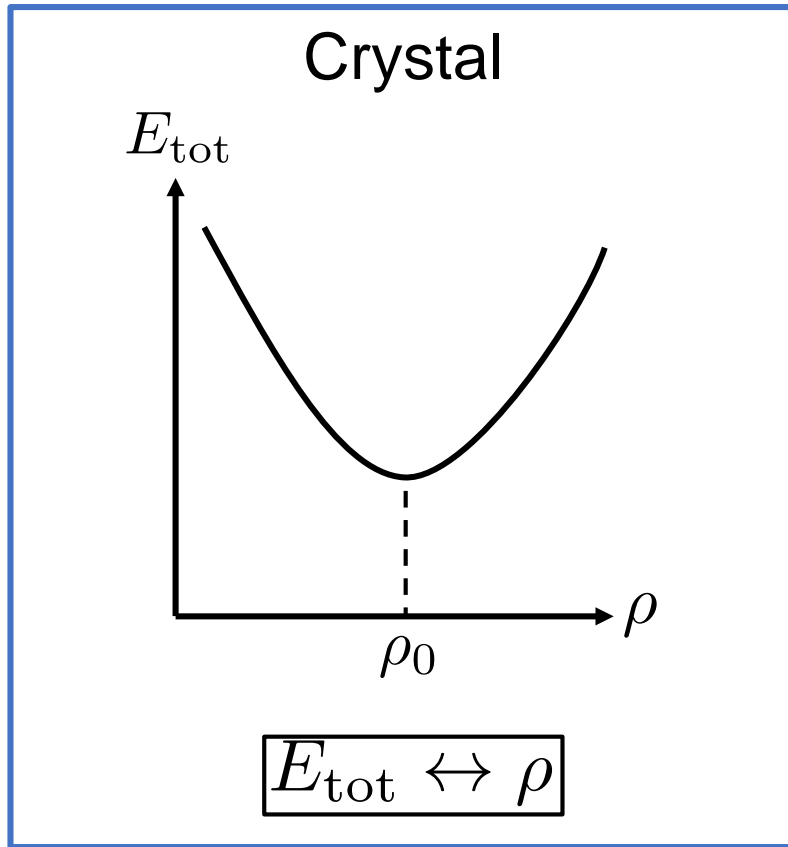
# Determining the densities of materials

The densities ( $\rho$ ) of crystalline materials are determined by calculating the total energy ( $E_{\text{tot}}$ ), since  $E_{\text{tot}}$  corresponds to  $\rho$



# Determining the densities of materials

Not for amorphous materials, because the structures are disordered

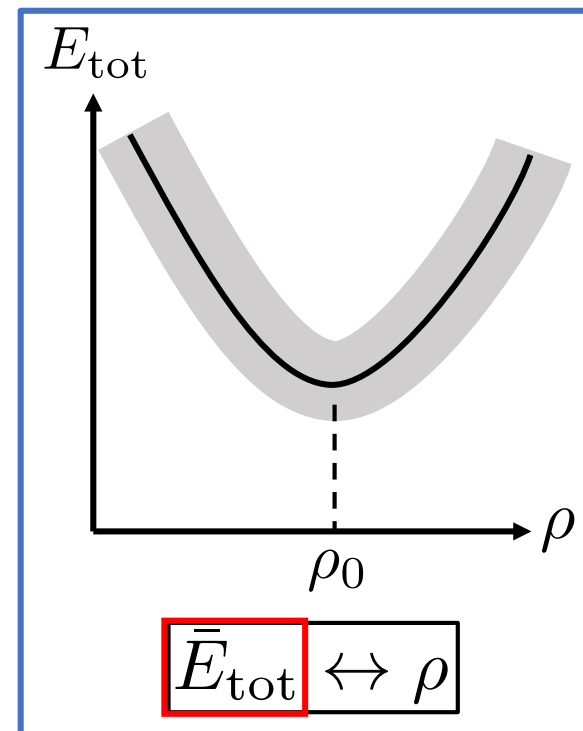
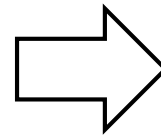
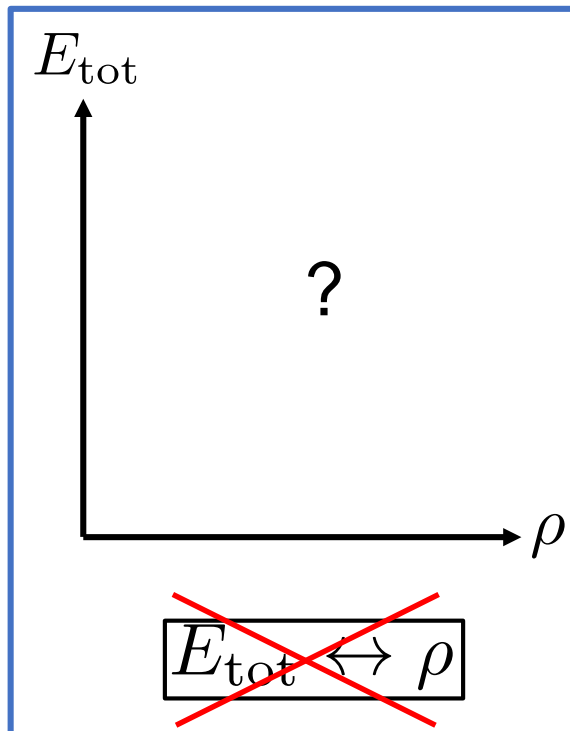
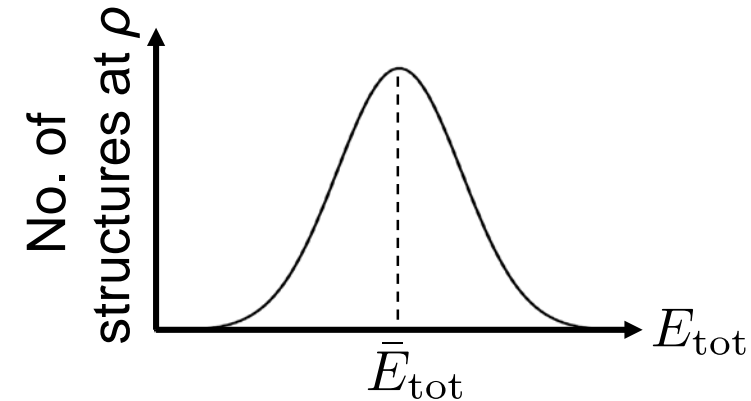


Any solution for amorphous materials? → our work

# An assumption

The canonical distribution of the amorphous samples form a Gaussian distribution

→ Then, the averaged energy corresponds to the density



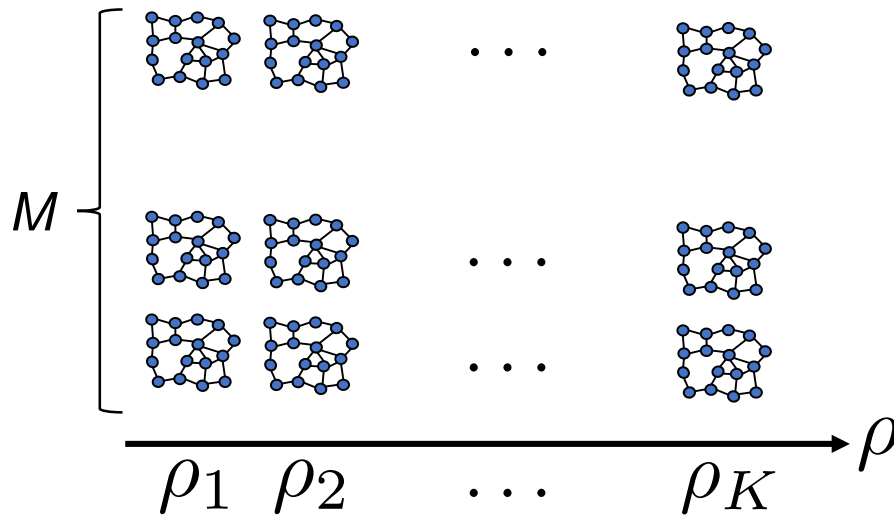
# Procedure to determine the density

1. Generate multiple samples  $(1, \dots, M)$  at different densities  $(\rho_1, \dots, \rho_K)$
2. Obtain their total energies from DFT
3. Average the total energies at each density
4. Find the density that minimizes the average  $\rightarrow \rho_0$



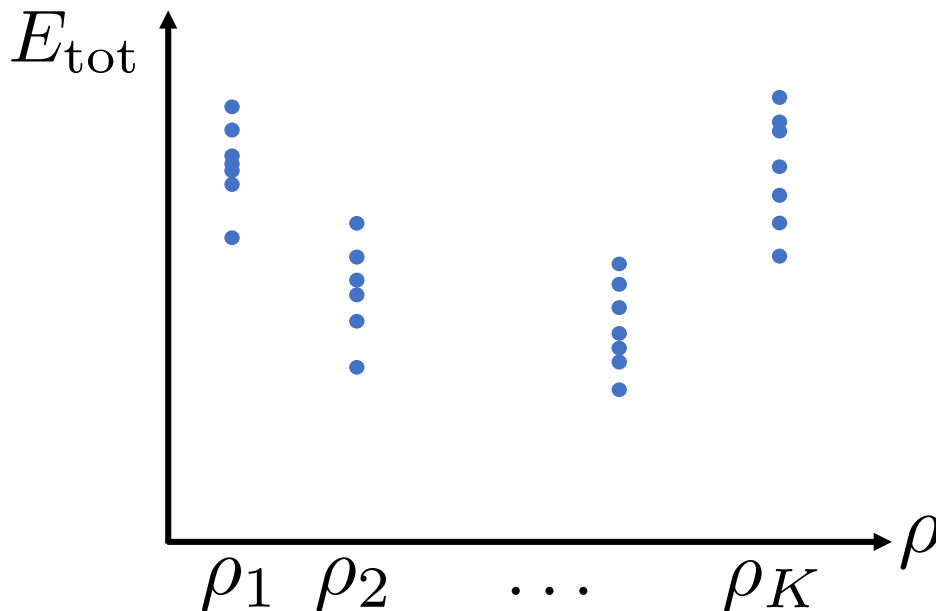
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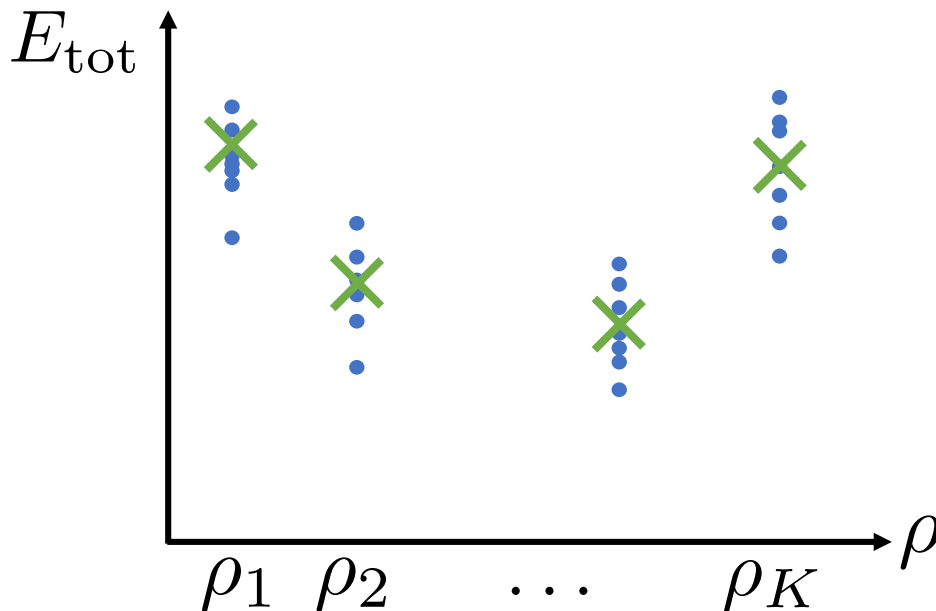
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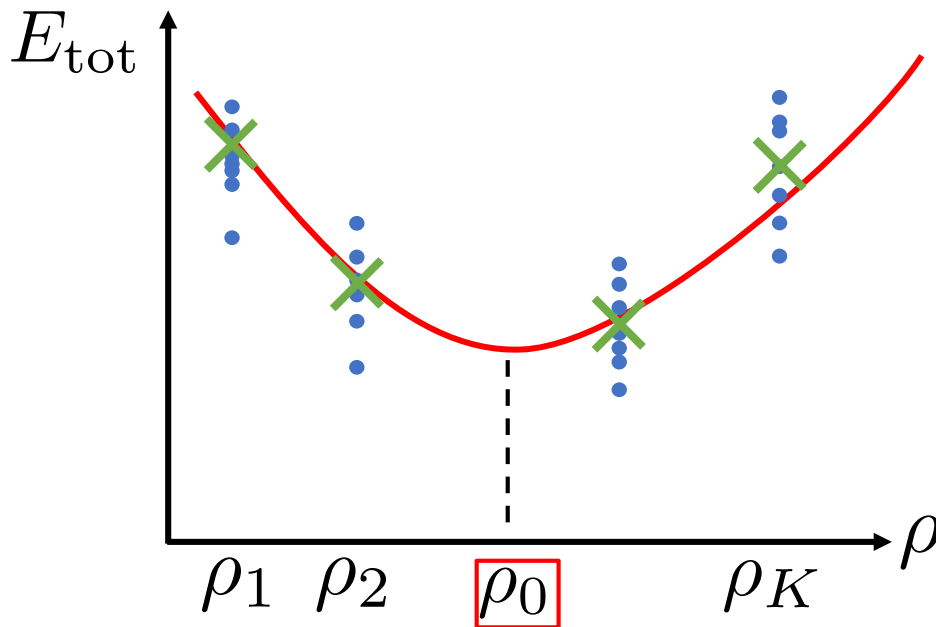
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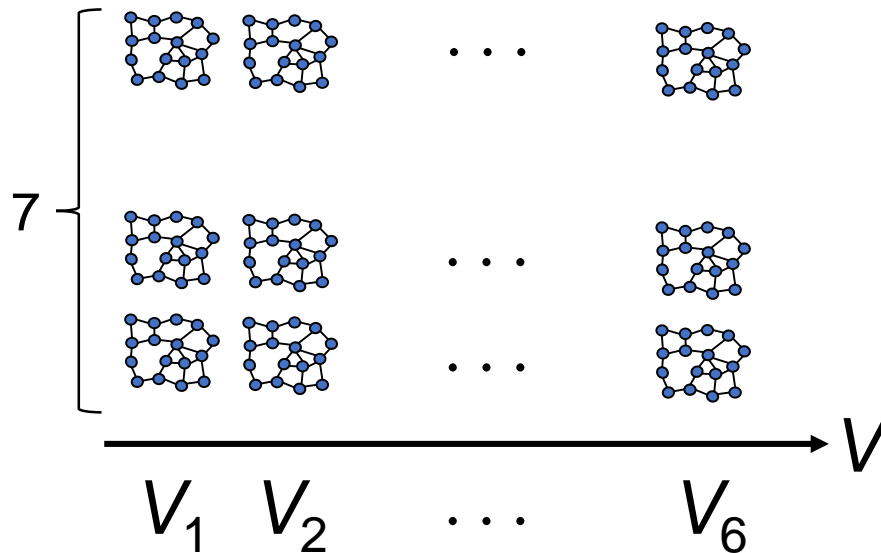
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$\rightarrow$  examined with amorphous Si (a-Si)

# Generating a-Si samples

- 1. Generate 7 samples at 6 different volumes  $V$** 
  - $V/V_C = 0.86 - 1.16$  ( $V_C$ : volume of crystal)
  - System: 54 Si atoms/cell with periodic boundaries

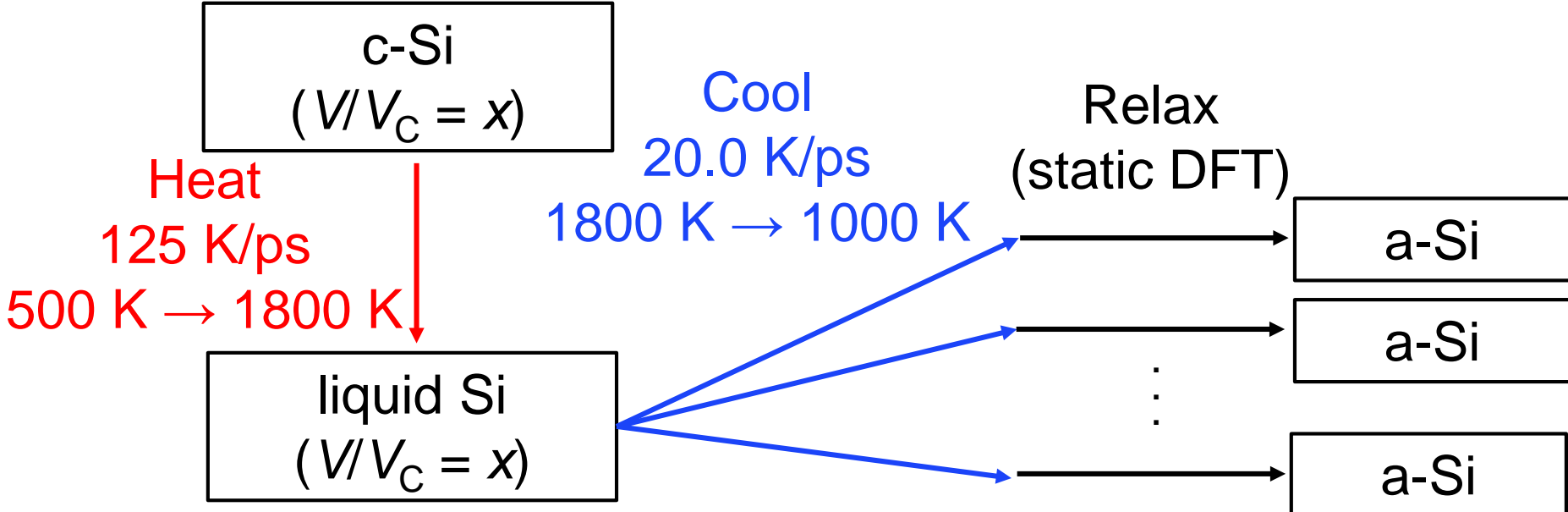


# Generating a-Si samples

## 1. Generate 7 samples at 6 different volumes $V$

- $V/V_C = 0.86 - 1.16$  ( $V_C$ : volume of crystal)
- System: 54 Si atoms/cell with periodic boundaries
- Melt-quench method by Car-Parrinello molecular dynamics (CPMD)

(functional=PBE, cutoff=40 Ry, BZ sampling= $\Gamma$  point)

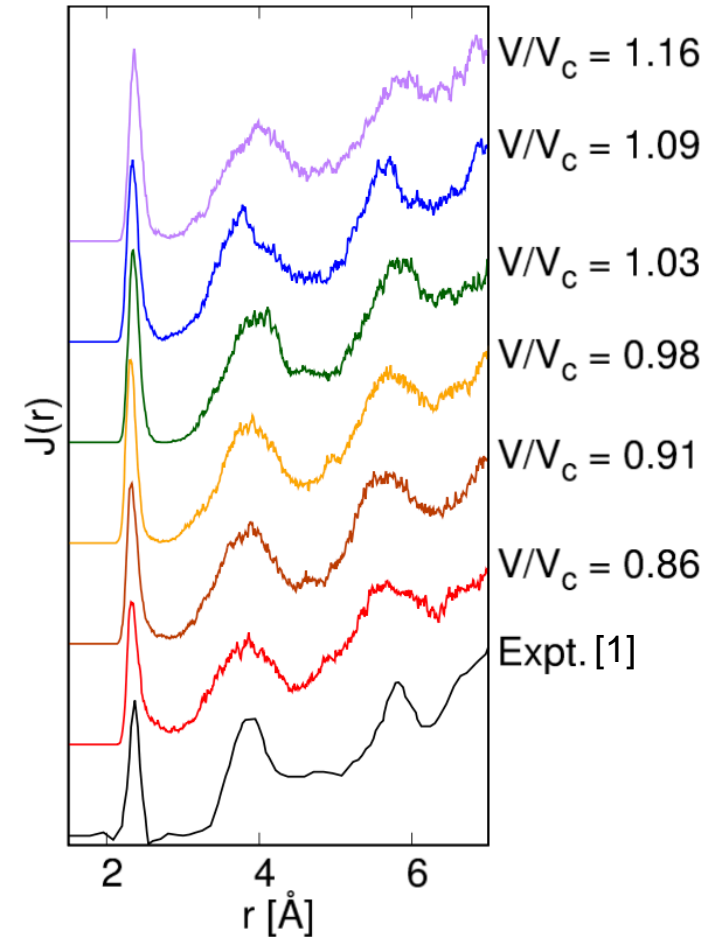


# Radial distributions of samples

Good agreement with experiments:

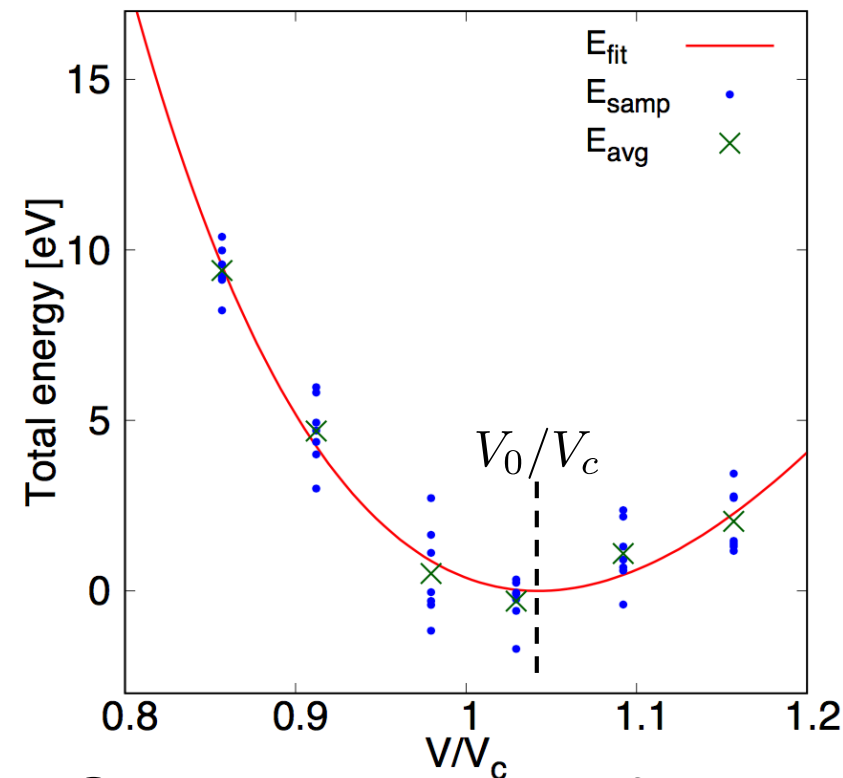
- First peak at  $\sim 2.3 \text{ \AA}$
- Broader peaks subsequently

→ Obtained samples are certainly valid a-Si



[1] PRB 60, 19 (1999)

# Total energies



	Calc.	Expt.
$V_0/V_C$	1.042	1.017 - 1.019 [1]
$B_0$ (a-Si)	61.27	36 – 95 [2]
$B_0$ (c-Si)	89.59	97.6 [3]

- Small variance of the samples' energies ( $< 1.6$  eV)
  - Both  $V_0/V_C$  and  $B_0$  (bulk modulus) agrees with expt.
- Our method works for a-Si

[1] Appl. Phys. Lett. **64**, 437 (1994)

[2] "Thin film materials", Cambridge University Press, (2003); PRB **58**, 8941 (1998)

[3] J. Microelectromech. Syst. **19**, 2 (2010)

# Results from MD simulations

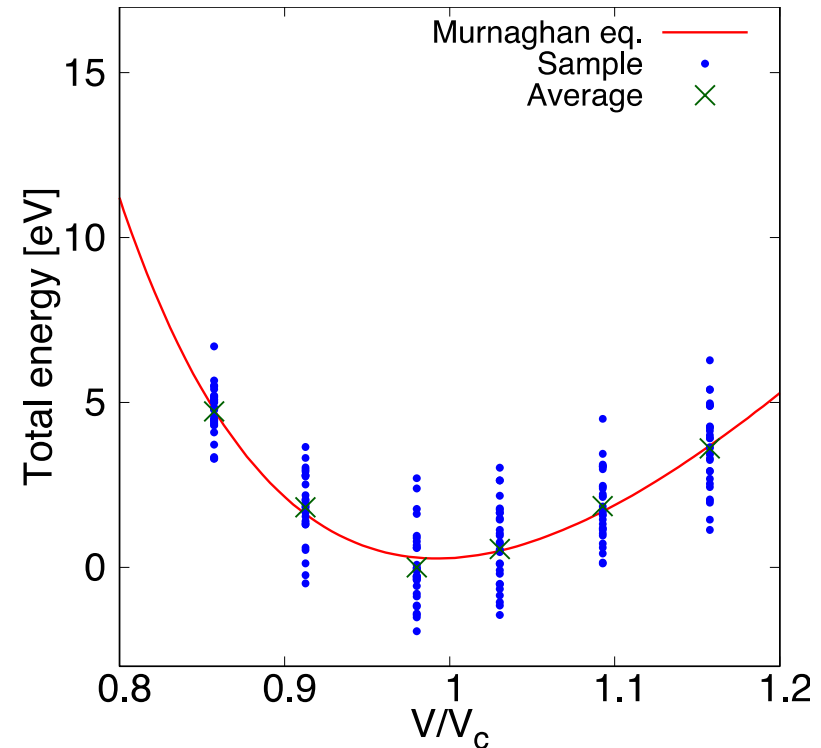
What if we generate samples by MD instead of CPMD?

Conditions:

- Tersoff potential
- 30 samples at each volume

Result:

- $V_0/V_C = 0.992$
- $B_0 = 49$  GPa

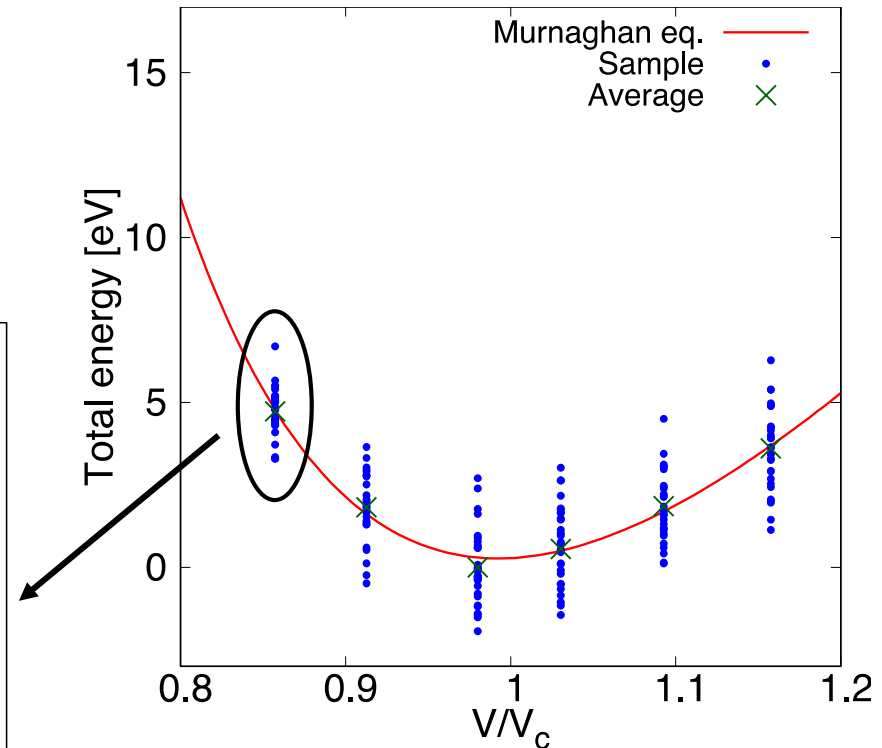
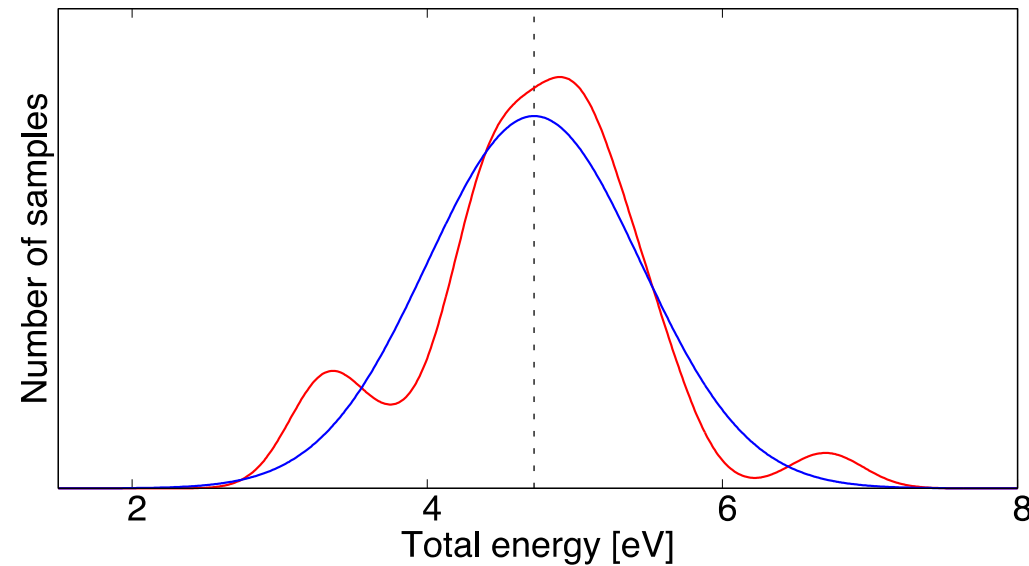


- It works, but the total energy is higher (3 eV/cell)
- CPMD-generated structures are energetically preferable

# Results from MD simulations

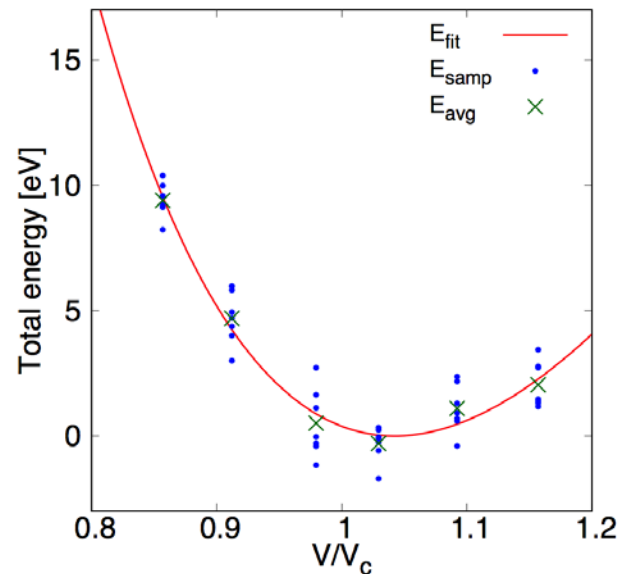
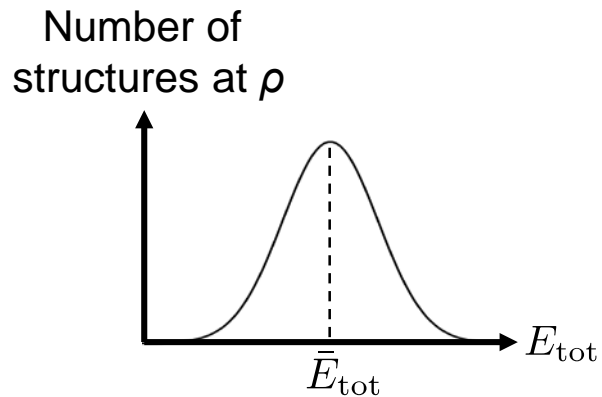
A finding: the sample distribution is close to Gaussian distribution

→ Supports our assumption



# Summary

- A method to computationally determine the density of amorphous materials is proposed
- For a-Si, both the density (volume) and the bulk modulus have been well reproduced
- Results from MD simulations imply the validity of our underlying assumption



(arxiv:1704.06107)